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EUROPEAN PATENT APPLICATION

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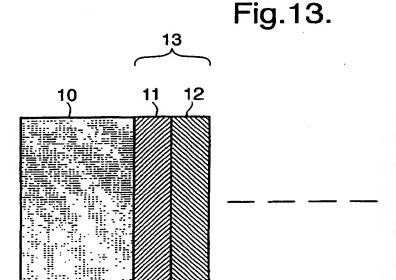
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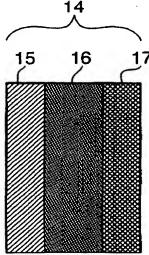
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- (54) EUV-Lithographic projection apparatus comprising an optical element with a capping layer
- (57) A lithographic projection apparatus comprises an optical element such as a multilayered EUV mirror (10,13,14) with protective capping layers (17) of diamond-like carbon (C), boron nitride (BN), boron carbide
- (B_4C) , silicon nitride (Si_3N_4) , silicon carbide (SiC), B, Pd, Ru, Rh, Au, MgF₂, LiF, C₂F₄ and TiN and compounds and alloys thereof. The final period (11,12) of a multilayer coating may also be modified (15,16) to provide improved protective characteristics.







EUROPEAN SEARCH REPORT

EP 00 30 5432

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